Supporting information

Title
Single-step preparation of large area TiO_2 photoelectrodes for water splitting

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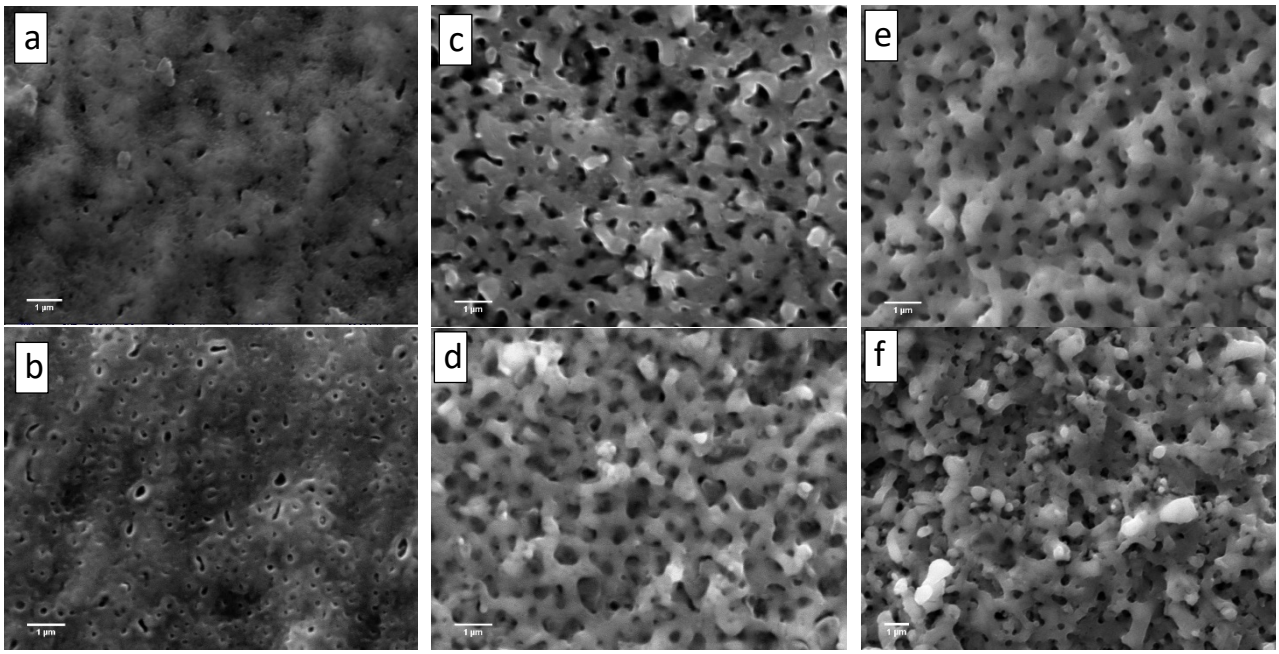

Figure S1. SEM surface images of TiO_2 films: (a) A-60, (b) A-900, (c) A-30, (d) A-300, (e) C-10, and (f) C-90.

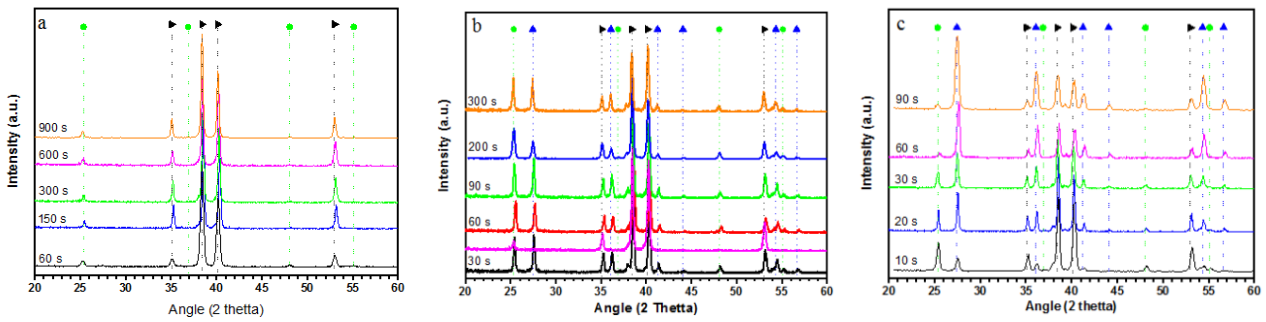

Figure S2. XRD pattern of TiO_2 electrodes obtained at different cell voltages and anodization times: (a) 100 V, (b) 150 V, and (c) 180 V. ● ▲ ▶ Symbols mark the reflection of anatase, rutile, and of the Ti substrate, respectively.

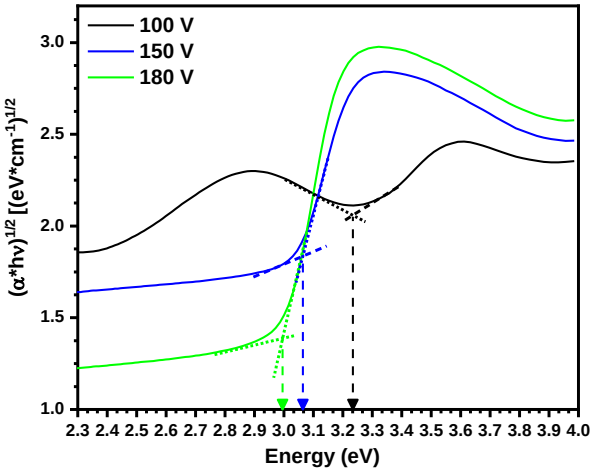

Figure S3. UV-Vis-NIR diffuse reflectance spectra (DRS) for some representative TiO_2 samples as Tauc-plots of the Kubelka–Munk transform.

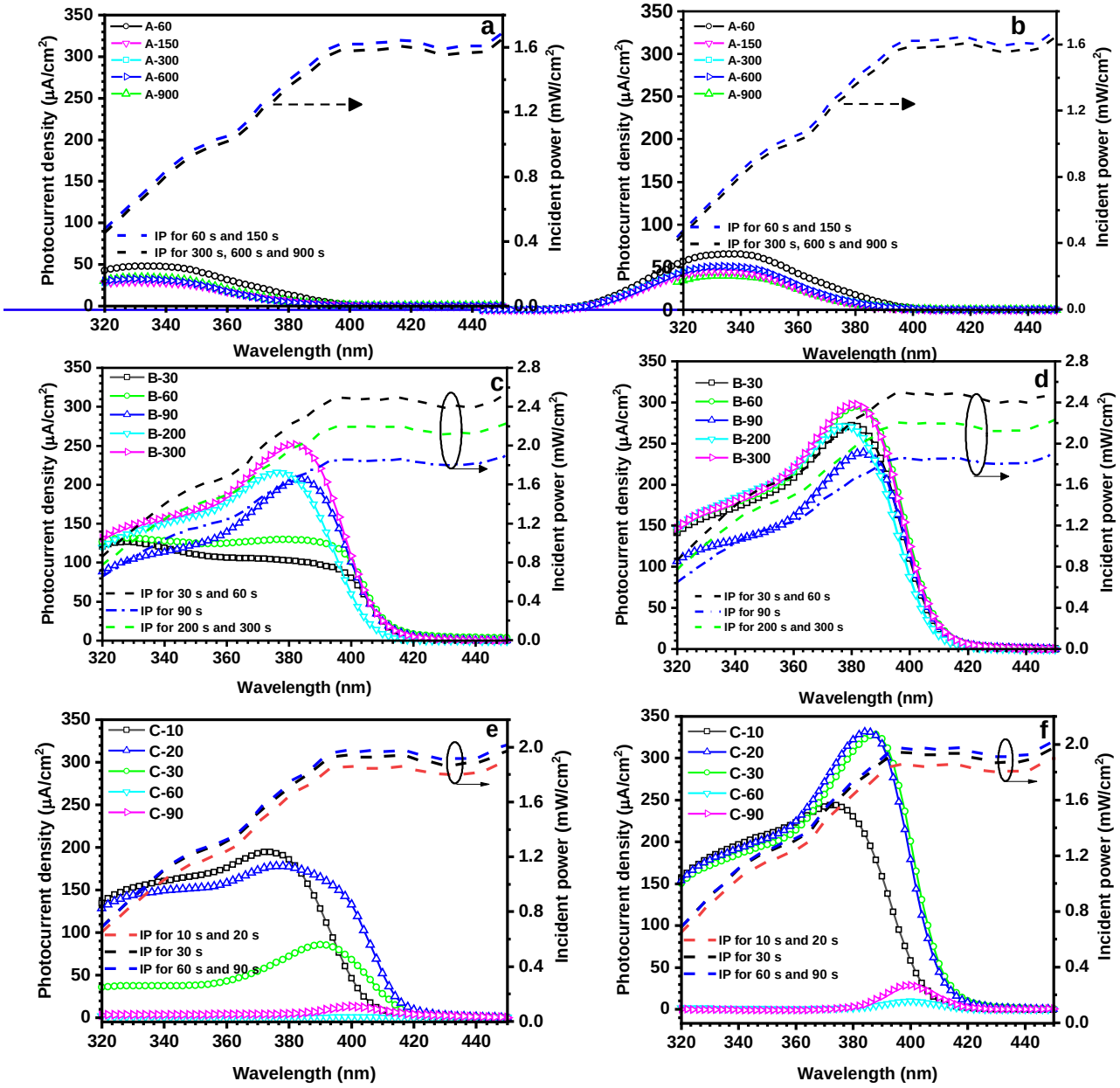

Figure S4. Photocurrent density vs. irradiation wavelength curves measured with TiO_2 electrodes obtained at (a,b) 100 V, (c,d) 150 V and (e,f) 180 V cell voltages and the anodization times indicated in the panels, (a,c,e) in the absence of applied bias and (b,d,f) under 0.6 V vs. SCE.